Microstructure and Properties of TiAlN/a-C Nanocomposite Coatings Prepared by Reactive Sputtering

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TiAlN/a-C nano-composite coatings were synthesized by a reactive co-sputtering process to investigate the effects of sputtering conditions on the microstructure and mechanical properties. Coating films were deposited on square plates of Si and high speed steel (ANSI M2) by the co-sputtering of TiAl (pulsed-d.c. sputtering) and C (d.c. sputtering) targets using a “Facing Target-type Sputtering” system at an atmosphere with a mixture of Ar and N2 but without hydrocarbon gas. The structure of the coatings was investigated by means of XRD, XPS and HRTEM with GIF (Gatan Imaging Filter). Mechanical properties of coating films were measured by a submicron indentation system.

Though TiAlN and a-C coatings showed hardness of about 32 and about 10 GPa, respectively, TiAlN/a-C coatings containing 4.6 at% of C showed higher hardness of 43 GPa. The energy filter images depicted that a change of contrast in the zero-loss image corresponded to nanocrystalline Ti-Al-N phase and amorphous structure. The existence of carbides and the relationship between the hardness and oxidation resistance of TiAlN/a-C coatings has not been elucidated satisfactorily.

Keywords: reactive sputtering, TiAlN/a-C, amorphous carbon, nano-indentation, nanocomposite coatings

1. Introduction

Transition metal nitrides or carbides are the most widely used coatings for tribological applications such as forming tools or cutting tools. On the other hand, amorphous carbon coatings, such as a-C, a-C-N, or a-C:H [called as diamond like carbon (DLC)], also have been widely applied to machining tools for aluminum, due to improved tribological properties in terms of low friction, high hardness and non-affinity to work material. However, at temperatures higher than 300°C, amorphous DLC or a-C changes to graphite and its hardness decreases drastically.

Recent studies of wear-protective coatings have been aiming at exploring multi component systems for improving hardness and/or oxidation resistance. Since Veprˇek et al. presented a theoretical concept for the super-hard “nano-composite” films and their experimental verification on the Ti-Si-N systems,1 nanocomposite coatings composed of crystalline/amorphous nanophases mixture have recently attracted much interest in fundamental research and industrial applications. Nanocomposite coatings consisting of different bonding structure have possibilities of synthesizing a surface protection layer with an unusual combination of mechanical and tribological properties such as high hardness and toughness, superior wear resistance and low frictions.2 In order to attain this goal, TiC/a-C,3,4 TiAlN/C or CrAlN/C coatings5–15 have been prepared by various methods, including arc ion plating (AIP), closed field unbalanced magnetron sputtering (CFUBMS), plasma enhanced chemical vapor deposition (PECVD). However, only a limited amount of research on TiAlN/a-C coatings prepared in the mixture of Ar and N2 gases without hydrocarbon gas has been conducted.

The maximum hardness of TiAlN/a-C coatings synthesized under the atmosphere containing hydrocarbon gas was in the range of 20 to 40 GPa, and the hardness is affected by flow rate of the gas.10 XPS analysis of these films showed that some carbon atoms bound as (Ti,Al)-C7,12 or (Ti,Al)-CN.13 These results indicate that the hardness of TiAlN/a-C coatings is affected not only by microstructure but also by the existence of carbides and the relationship between the microstructure and mechanical property of TiAlN/a-C coatings has not been elucidated satisfactorily.

To study the effect of carbon on the microstructure and mechanical properties of coatings, a series of TiAlN/C coatings has been deposited by a reactive magnetron sputtering of TiAl and carbon targets in a mixture of Ar and N2. In the previous reports7,12,13 the films deposited by a reactive sputtering using hydrocarbon gas contain some amount of carbides. In order to eliminate the possible formation of carbide bonding, no hydrocarbon gas was used.

2. Experiment

Square of 25 mm × 25 mm mirror-polished silicon wafers and high-speed steel plates (SKH-51) were used as substrates. All the substrates were cleaned ultrasonically with acetone, ethanol and 2-propanol sequentially before sputtering deposition.

Coating deposition was performed with a reactive sputtering apparatus that has two targets (TiAl-TiAl and C-C) of targets facing each other (referred to as the “Facing Target-type Sputtering (FTS) system”; Osaka Vacuum Co., Ltd., FTS-2R). Rectangular (100 mm × 160 mm × 10 mm thickness) Ti50Al50 alloy (99.8%) and carbon (99.9%) targets were sputtered in a mixture of highly purified argon and nitrogen.
gases (99.9999%) without hydrogen gas. The system was first evacuated to a vacuum better than $5 \times 10^{-5}$ Pa ($= 3.8 \times 10^{-7}$ Torr) prior to deposition. Based on the result of our previous study of TiAlN film preparation, the flow rate of Ar and N$_2$ gases was fixed at 15 sccm and 20 sccm, respectively. The working pressure was kept at 0.15 Pa (1.1 mTorr). The pulsed d.c. power (frequency: 120 kHz, duty cycle: 84%) and normal d.c. power were supplied to TiAl alloy targets and to carbon targets, respectively. The substrates were heated up to about 200°C without applying negative bias voltage during deposition. The deposition rates were about 28 nm/min and 0~6 nm/min for TiAlN and C coatings, respectively. Substrates were rotated at 30 rpm during the deposition. The thickness of the TiAlN/a-C composite coating was controlled at about 2.0 μm by controlling the sputtering time. Mixing ratio of TiAlN and C was controlled in the range of 100 : 0 to 83 : 17 (volume fraction) by adjusting incident power of graphite targets. The volume fraction can be monitored from the deposition rate of TiAlN and amorphous carbon coatings.

Composition of coating was analyzed by EPMA (JEOL, JXA-8200D) and quantified with ZAF (Z: atomic number effect, A: Absorption effect, F: Fluorescence excitation effect) correction method without standard samples of carbon and nitrogen. The crystal structure of coatings was identified by an X-ray diffractometer (Philips, X’pert system) using Cu-Kα radiation with 0~2θ or grazing angle mode (GAXRD). The microstructure of coatings was investigated by TEM (TOPCON, EM-002B), HRTEM (JEOL, JEM4010T) equipped with GIF (Gatan Imaging Filter), and XPS (Thermo VG Scientific, Sigma Probe) using Mg Kα radiation.

Indentation hardness$^{[10,17]}$ and effective Young’s modulus$^{[18]}$ of coatings were measured with a submicron indentation system (Fisher, HC-100XYp) at room temperature using a triangular Berkovich diamond pyramid. The load was selected to keep an impression depth ratio below 10% of coating thickness so that the influence of the substrate can be neglected.

3. Results and Discussion

Table 1 indicates the chemical composition and the mechanical properties of the TiAlN/C coatings, and the comparison of TiAlN and amorphous carbon (a-C) coatings deposited at the same condition as TiAlN/C coatings. The atomic ratio of Ti/Al for all TiAlN/a-C coatings (S-1~S-4) was a little higher than that of the target (Ti/Al = 0.98), the ratio was kept between 1.02 and 1.05. Nitrogen content of coatings was kept in the range of 50 to 52 at%. TiAlN (S-1) and a-C coatings has hardness of 32 GPa and 10 GPa, respectively. A small amount of carbon addition (about 6 vol%) increased hardness a little in spite of low hardness of a-Carbon. However, TiAlN/9 vol%C (= 4.6 at%) (S-3) coating shows the highest hardness (about 43 GPa). With additional amount of a-C, the hardness of S4 coating (8.5 at%) was decreased to 22 GPa. On the contrary, Young’s modulus decreased monotonically with increasing carbon addition. Especially, the Young’s modulus of S-3 coating is decreased from 287 GPa to 265 GPa by the addition of 4.6 at%C. Note that high hardness with low Young’s modulus is the characteristic of nanocomposite coating.$^{[1] }$ From these results, we decided to investigate the difference in microstructure and properties of S-1, S-3 and S-4 coatings.

Figure 1 shows glancing angle incidence XRD patterns of TiAlN and TiAlN/a-C coatings containing different concentration of carbon. Only one phase of the cubic B1 NaCl type structure was observed excepting the peak from substrate (Si). A drastic change of main peaks of B1-TiAlN from (200) in S-1 coating to (111) and (220) in S-2 coating indicates that a small amount of carbon addition (about 6 vol% of carbon) appears to change the preferred orientation of the coating. With further increment of carbon content (S-3, S-4), TiAlN peaks become broader. Dark-field TEM micrographs reveals that crystal grain size decreases with the increases of carbon content (Fig. 2). Figure 3 illustrates grain size measurement based on dark-field TEM micrographs of in plan views and XRD peak width. As for the TiAlN/4.6 at%C coating, grain sizes measured from dark-field TEM of cross-sectional view were added in the Fig. 3. These results revealed that grain sizes decrease monotonically with an increase of carbon content. The grain width of TiAlN/4.6 at%C coating measured from dark-field TEM of cross-sectional views is about
10~12 nm, which is consistent with the size measured from plan-view, and the grain length measured from cross-sectional views is in good agreement with the size estimated from XRD peak width.

TEM observation reveals the strong correlation between the carbon content, grain size and morphology in more detail (Figs. 4 to 7). A plan-view TEM image and SAED (selected area electron diffraction) pattern of TiAlN/4.6 at%C coatings shows the single phase of the TiAlN B1-NaCl type structure with the grain size of about 10 nm. No other crystalline phase was found (Fig. 4(a)). Figure 4(b) depicts an HRTEM plan-view image of TiAlN/4.6 at%C coating. Areas surrounded by dotted line in the figure indicate a typical example of amorphous like phase in the film. It is obvious that TiAlN grains in the range of 5~10 nm are surrounded by amorphous like phase.

Figure 5(a) shows the bright-field TEM image and electron diffraction pattern of a cross-sectional view of TiAlN/4.6 at%C coatings. The diffraction pattern does not exhibit strong preferred orientation. The diameter of columns was decreased with additional carbon as compared with TiAlN coatings. For an example, the averaged column width of TiAlN and TiAlN/4.6 at%C were about 40 nm and about 10 nm, respectively. TiAlN columnar grain of about 10 nm in width and over 20 nm in length, which is so-called “nano-column”, is observed in Fig. 5(b) (TiAlN/4.6 at%C). In the case of cross-sectional view TEM samples, as more than several columns overlap along the incident direction of electron beam, amorphous-like phase between TiAlN grains is not observed clearly.

Figure 6(a) shows a plan-view TEM image of TiAlN/8.5 at%C coatings and the corresponding SAED pattern. The monotonic contrast with numerous small high electron dense (dark) particles and diffused halos in the electron diffraction pattern indicated the coexistence of amorphous and nano-crystalline materials in the coating. HRTEM image of TiAlN/8.5 at%C coating also reveals nano-crystallites circles dispersed throughout in the amorphous matrix (Fig. 6(b)). Although the carbon content in TiAlN/8.5 at%C coating is similar to that of Ti-Al-N-C coatings in the range of 9.5 to 13.5%C reported by M. Steuber et al., the microstructure revealed by TEM was completely different. Instead of partially diffused SAED pattern and “fibre-like structure (average column diameter is about 50 nm for 13.5%C coatings)” found by them, the diffused broad SAED pattern with dispersed nano-crystallites in amorphous matrix was observed in this study. Further investigation is required to fully understand the microstructure difference between these reports.

Figure 7 depicts energy filter TEM (EFTEM) images of the plan-view sample of TiAlN/4.6 at%C. As can be seen in the Fig. 7, several nanometer size of agglomerates were observed both in the Zero-loss image (Fig. 7(a)) and Ti map...
(Fig. 7(b)). They indicate that a change of contrast in zero-loss image accompanies the change of composition of Ti. On the other hand, as C and N maps only with a relatively homogeneous distribution were obtained. However, the spaces among the agglomerates are in the range of $1 - 2 \text{ nm}$, which correspond to the amorphous like areas in Fig. 4(b).

To minimize the adventitious carbon contamination, the outermost surface of the coating was removed using Ar$^+$ ion beam etching for 1.8 ks prior to XPS analysis. Figure 8 depicts the XPS C1s and N1s spectrum of TiAlN/4.6 at%C. In the N1s spectrum, three components were revealed and assigned to the binding energies of 396 eV, 398.1 eV and 401.9 eV, respectively. The curve fitting analysis indicated that the first component is N-(Ti,Al) and the second component is N-C $sp^2$. But, the last component is unclear, which is likely to be organic N-C bonding. This result revealed that nitrogen bound mostly with transition metals (396 eV) and with carbon (398.1 eV). Analysis of C1s spectrum revealed that carbon in the coatings bound almost as C-C (284.4 eV) with some bondings of C-N $sp^2$ (285.9 eV) and C-N $sp^3$ or C-O (288.3 eV). In the C1s spectrum, there is no evidence for bondings of Ti-C or Al-C (281.3~282 eV).

Stueber et al. reported that 5 bands at 281.8, 283.7, 285.5, 286.5 and 287.9 eV were fitted in the C1s spectrum of
TiAlN/28 at%C coating deposited by reactive magnetron sputtering of a TiAl target in a mixture of Ar, N\textsubscript{2} and CH\textsubscript{4} gases. According to their result, the peak at 281.8 eV or 285.5 eV was stronger than others, and the former peak was attributed to Ti-C bonding and the latter one was to C-OH bonding. They kept substrate temperature at 400°C and bias voltage at −80 V. On the other hand, in this study, the coatings were deposited with TiAl and carbon targets at 200°C in the mixed gases of only Ar and N\textsubscript{2}. The different bonding state of the TiAlN/a-C coatings perhaps attributed to the difference in the sputtering condition, especially to the difference in the carbon source.

Based on these considerations, we can conclude that nano-composite structure consisting of complicated mixture of nanocrystalline Ti-Al-N and amorphous carbon phase (with a small amount of C:N phase) existed in the TiAlN/a-C coatings.

**4. Conclusions**

TiAlN/a-C coatings have been prepared by pulsed d.c. and d.c reactive sputtering using 2 sets of TiAl and carbon targets in the FTS system. Evaluation of mechanical properties by submicron indentation and microstructure study of these coatings using XRD, HRTEM, EFTEM and XPS have drawn the following conclusions: The indentation hardness and the effective Young’s modulus increase with the addition of a about 9 vol% (4.6 at%) carbon without applying a bias voltage to the substrate. The hardness of TiAlN/a-C coatings reaches a maximum of 43 GPa for 4.6 at%C coating. On the other hand, Young’s modulus decreased from 287 to 265 GPa.
from 0 to 4.6 at% C. The HRTEM image and Ti map of EFTEM revealed that TiAlN nanocolumns were embedded in an amorphous like phase. Furthermore, XPS analyses indicated that carbon atoms in the coating have C-C bonding mainly with small amount of C-N bonding without any bonding of metal carbide. Accordingly, TiAlN/C coating is a nanocomposite coating that consists of a mixture of nano-crystalline Ti-Al-N and amorphous carbon (with a small amount of C-N phase).

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